



2026 9th International Workshop on Low Temperature Bonding for 3D Integration : Satellite in Kanazawa

Best Presentation Award

Room temperature bonding of Cr:LiSAF and sapphire:
interface analysis and thermal properties

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Best Presentation Award

Xenon vs Argon Ion Activation for Room-Temperature
Wafer Bonding of Si and SiC

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Best Poster Presentation Award

Effect of Temperature Ramping Rate on Thermal Expansion of Nanocrystalline Cu pads in Fine-Pitch SiO₂ Vias for 3D IC Hybrid Bonding

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